

FIG.1A

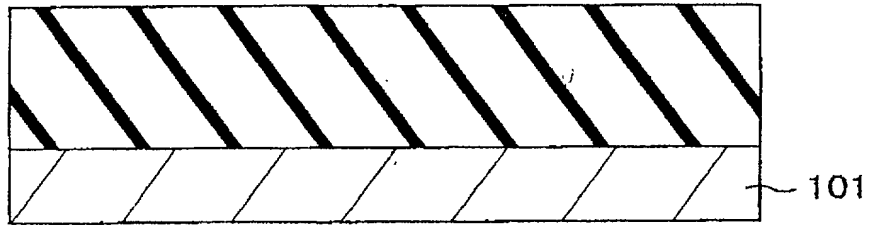


FIG.1B

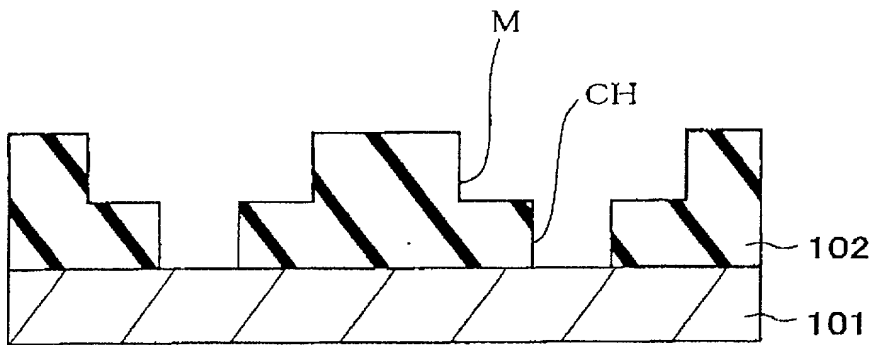


FIG.1C

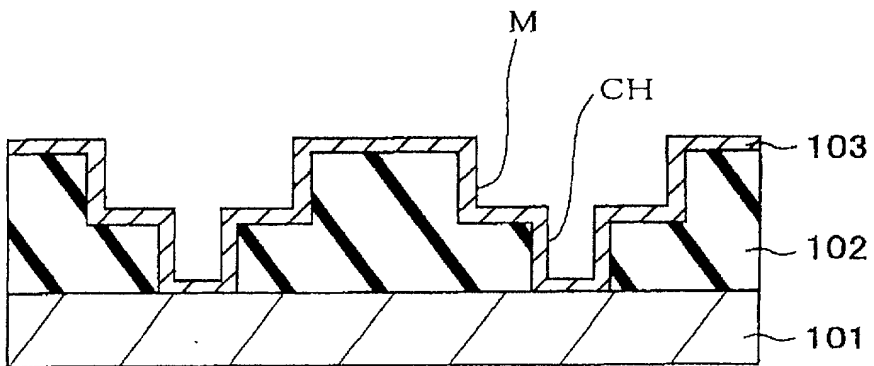


FIG.2A

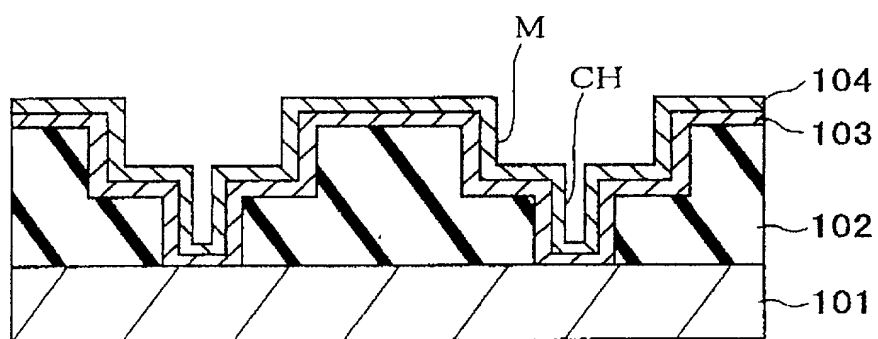


FIG.2B

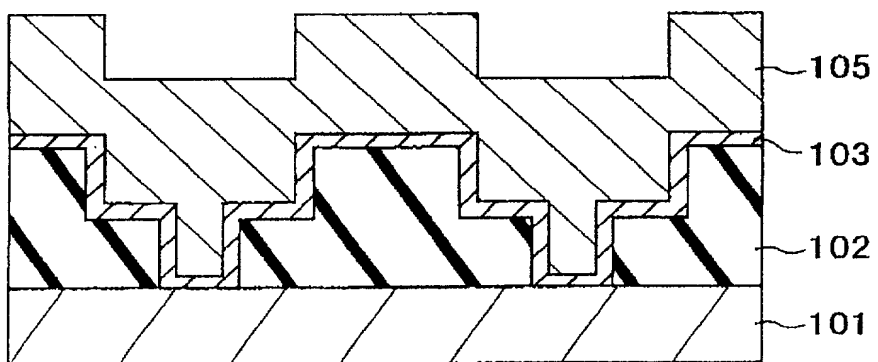


FIG.3A

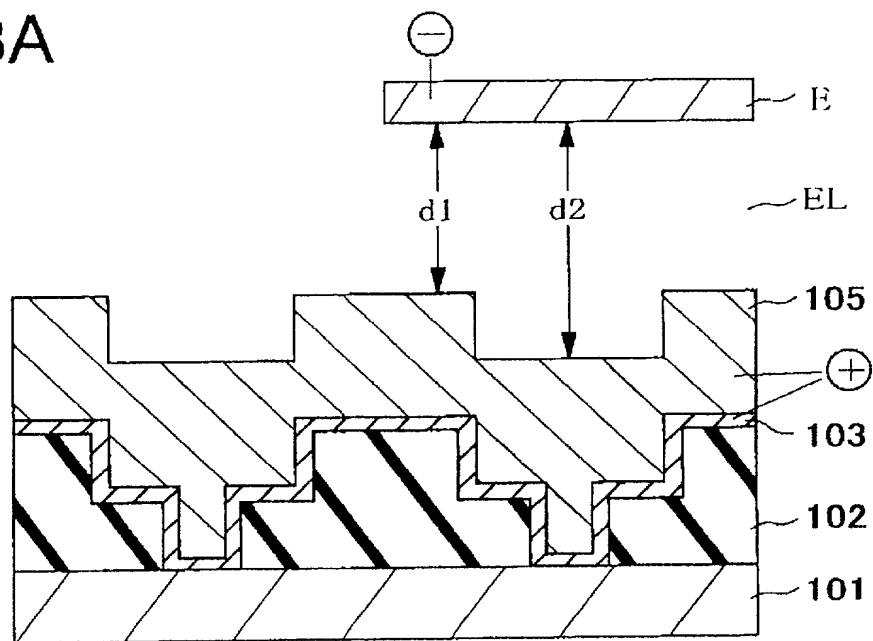


FIG.3B

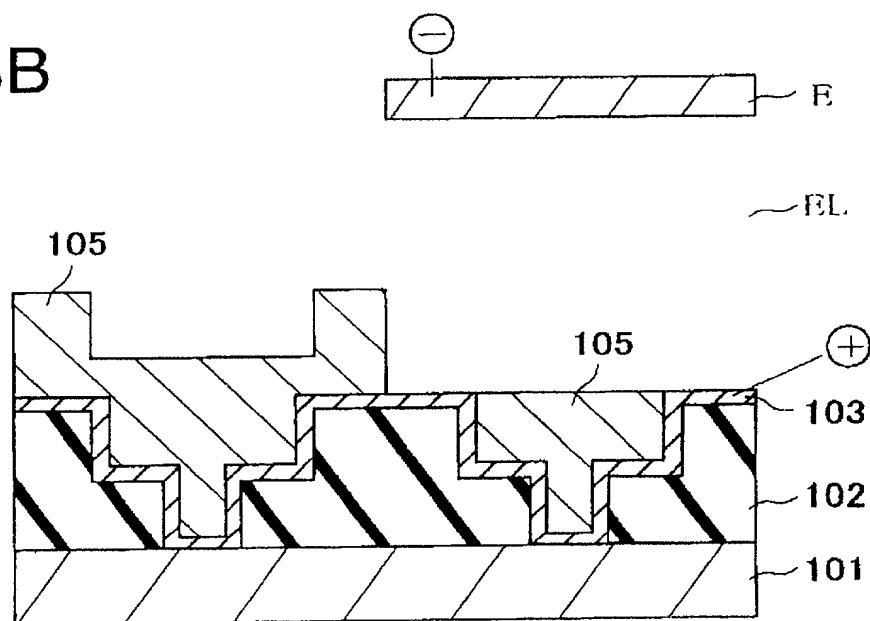


FIG.4A

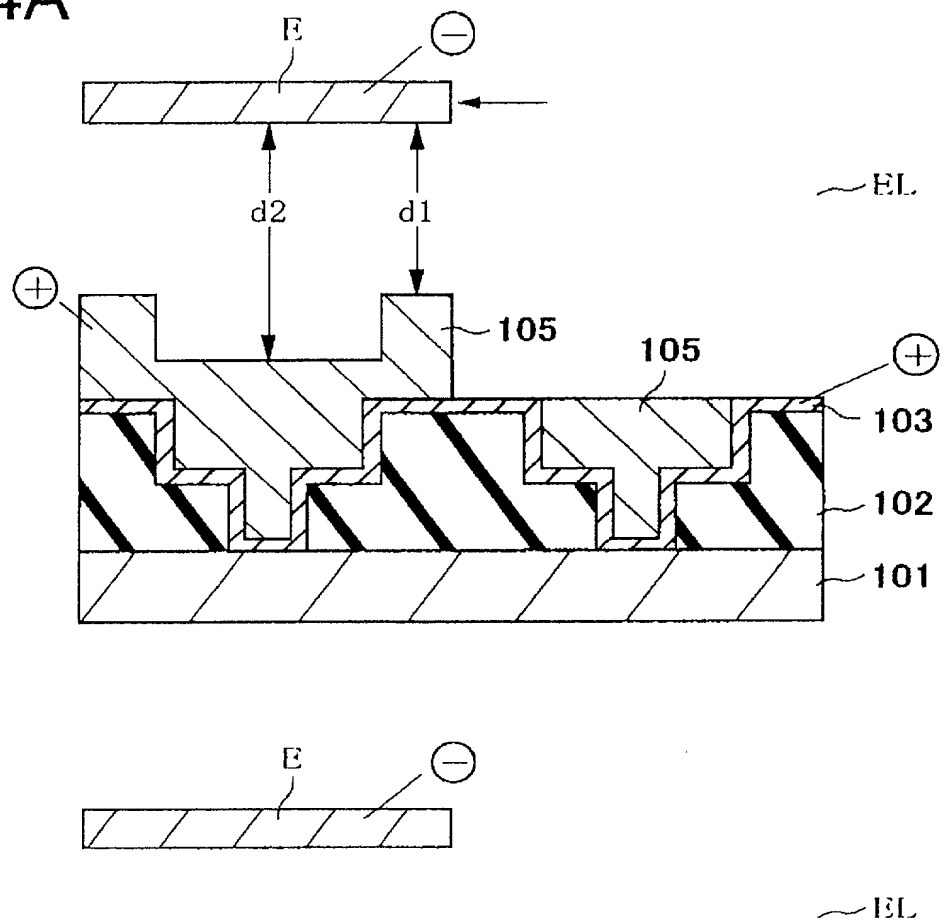


FIG.4B

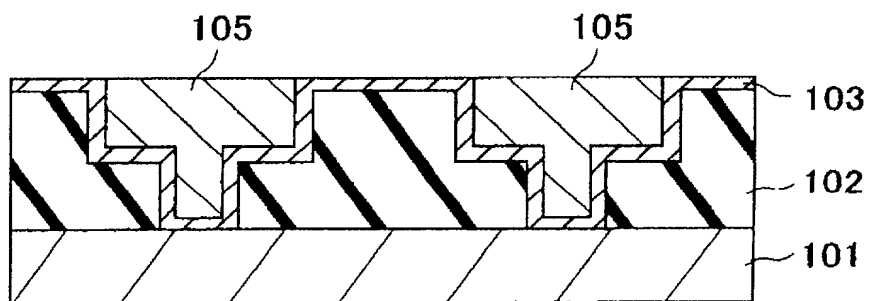


FIG. 5

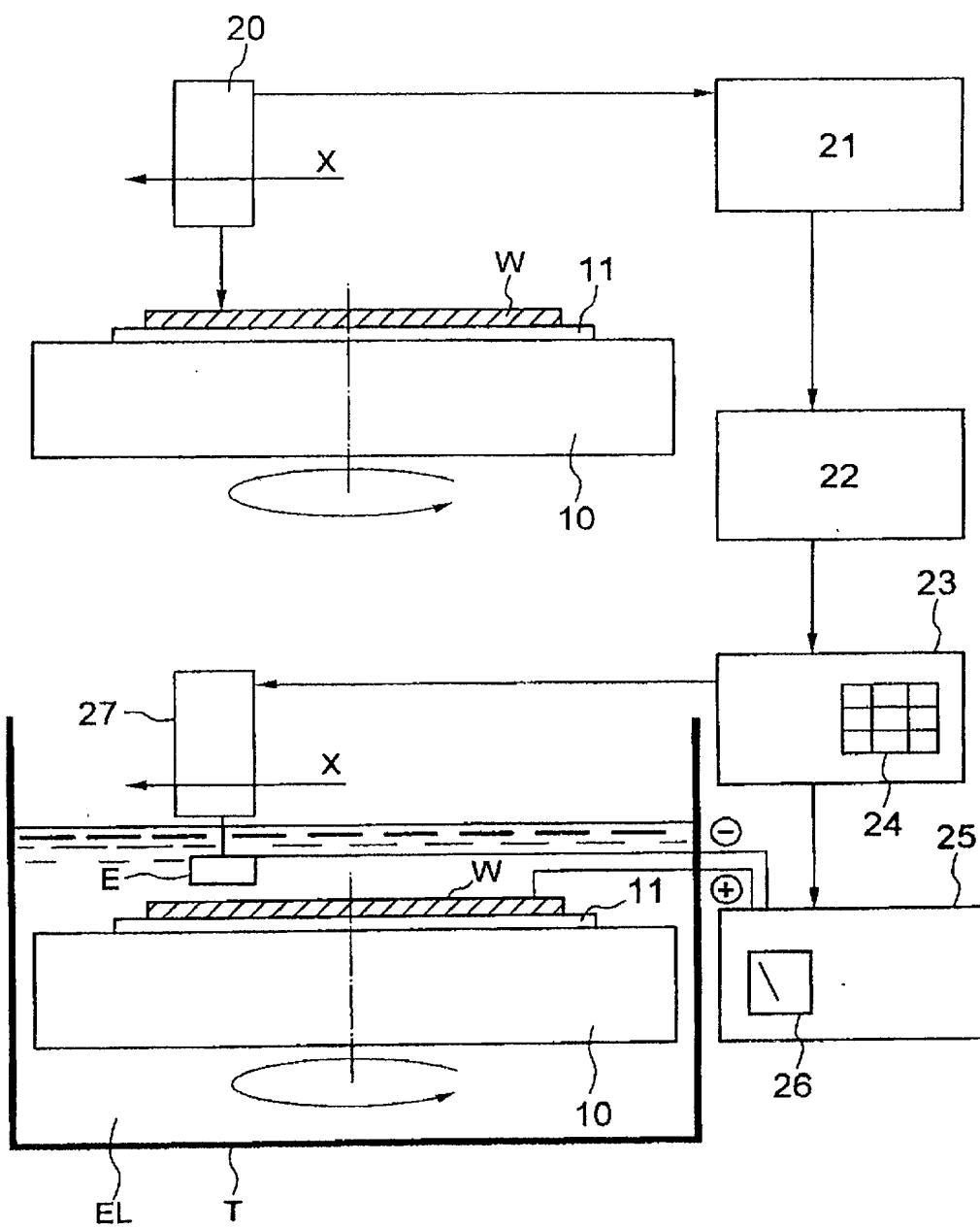


FIG.6A

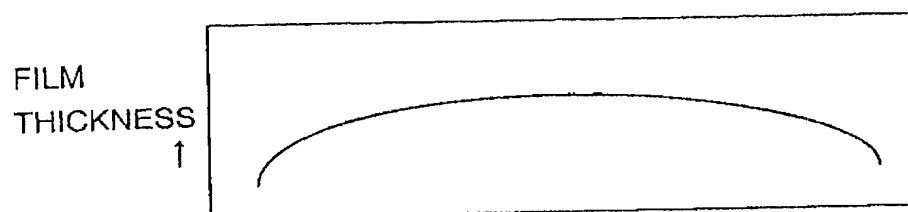


FIG.6B

AMOUNT OF
REMOVAL
↑

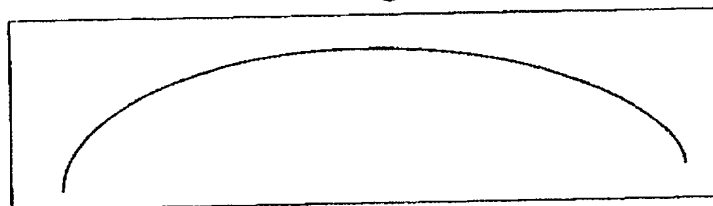
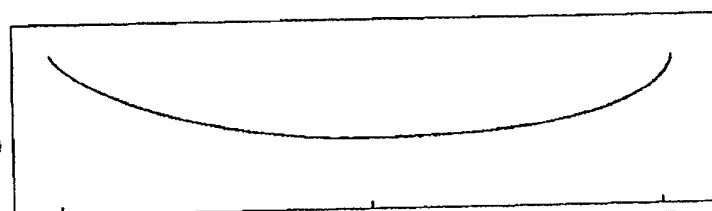


FIG.6C

ELECTRODE
MOVING SPEED



ED

CT

ED

X (POSITION ON A WAFER)

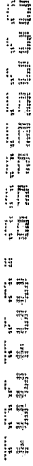
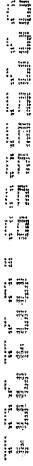
[illegible][illegible]

FIG. 8A

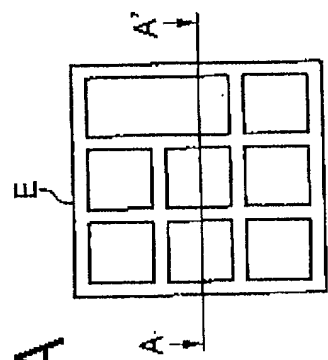


FIG. 8B

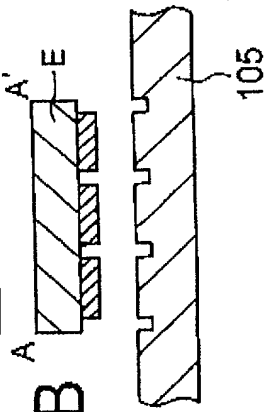


FIG. 8C

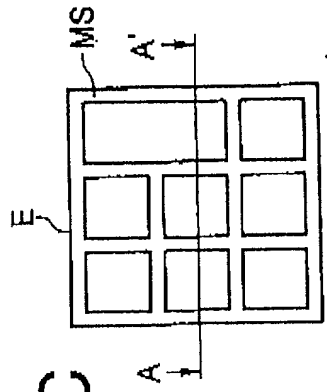


FIG. 8D

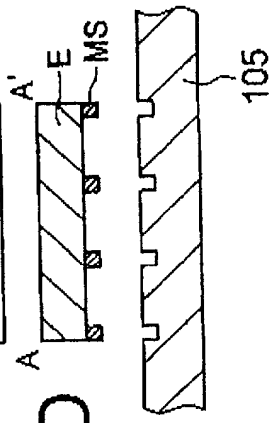


FIG.8E

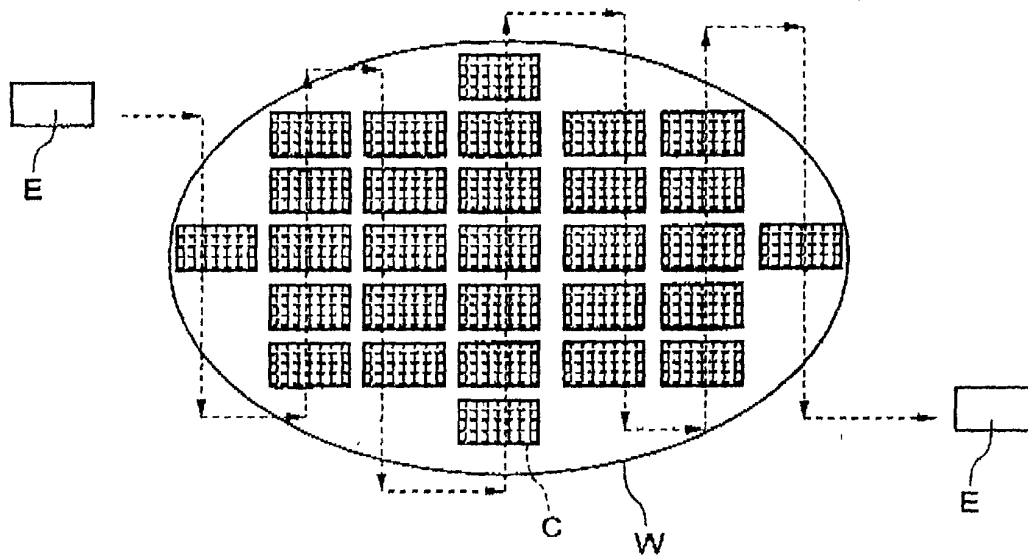


FIG.9A

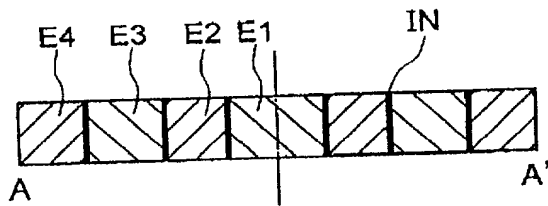


FIG.9B

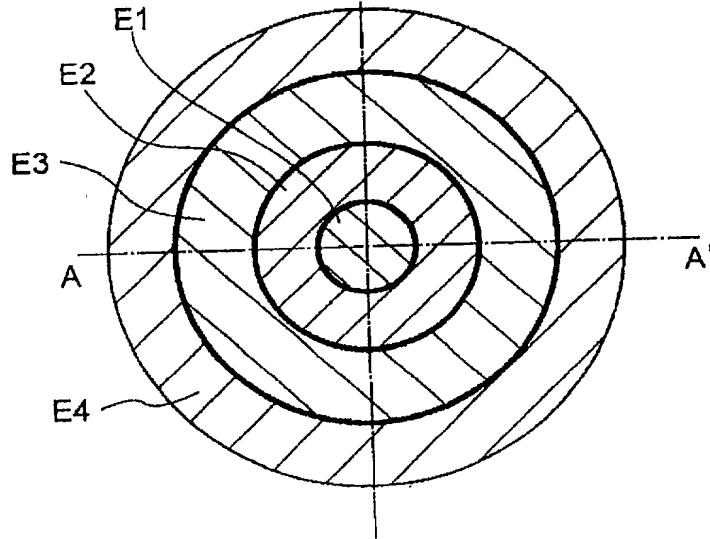


FIG.10A

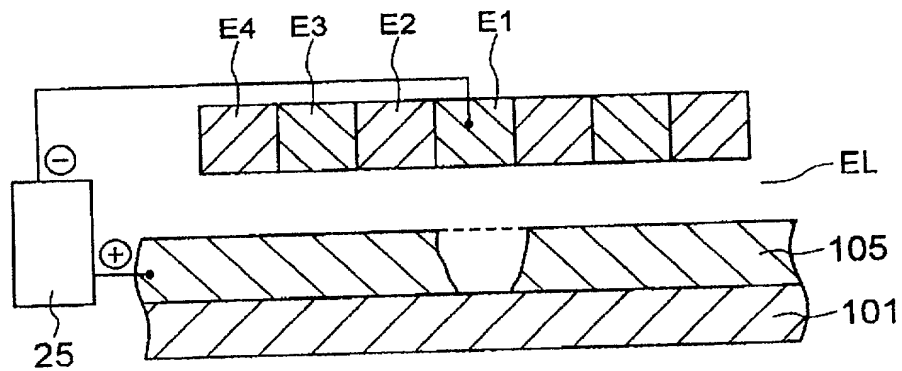


FIG.10B

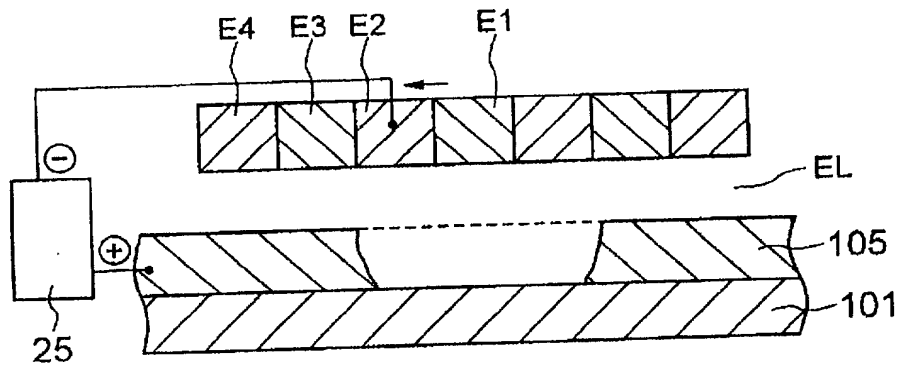


FIG.10C

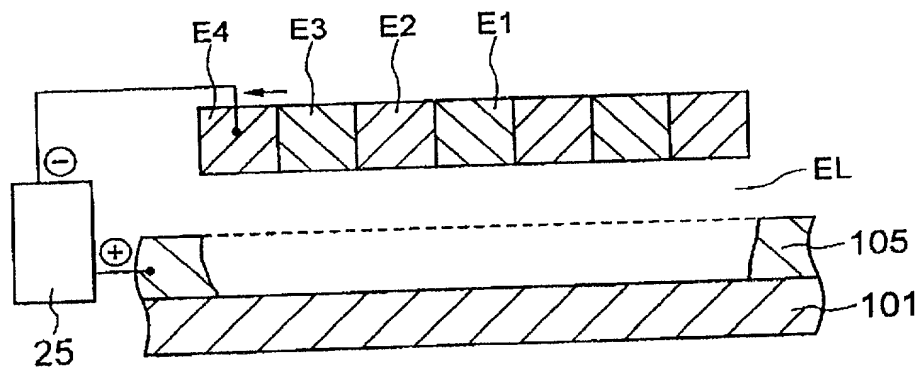


FIG.11A

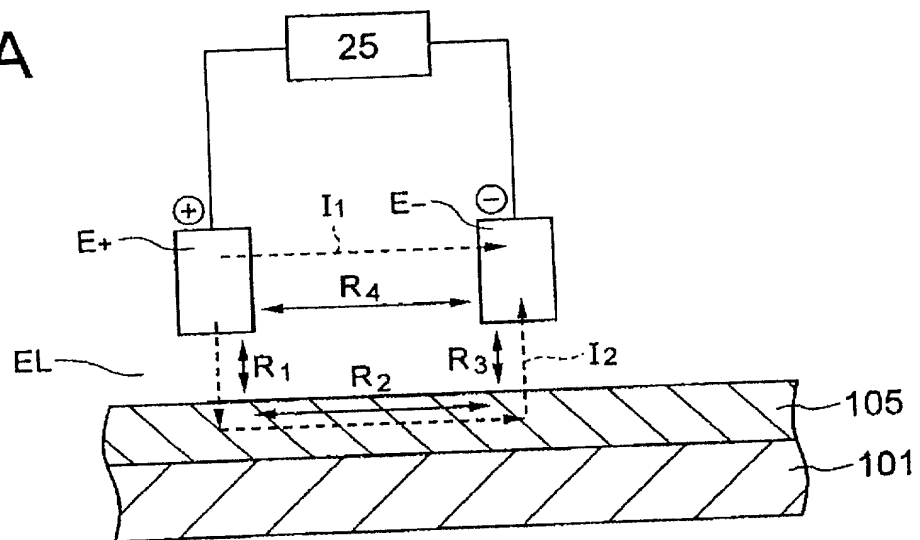


FIG.11B

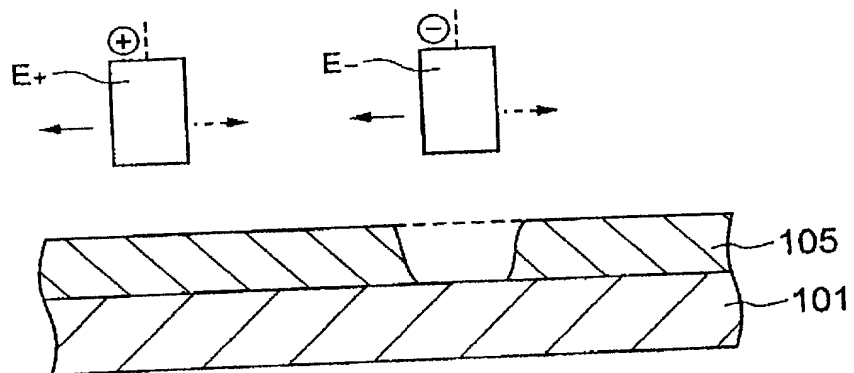


FIG.12A

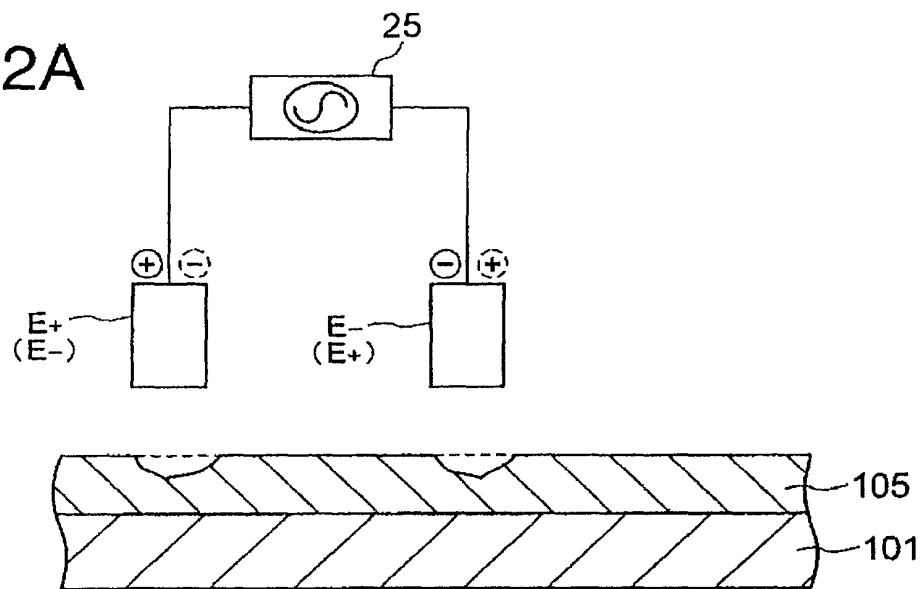
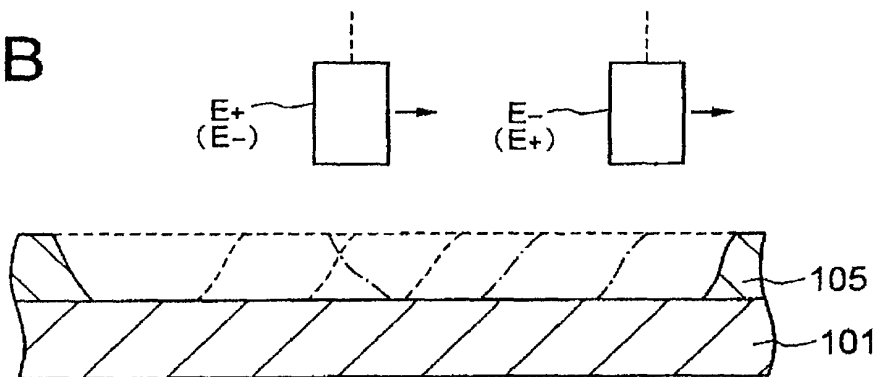
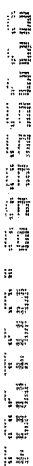
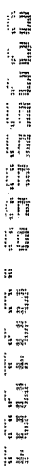


FIG.12B



[illegible][illegible]

Year	1970	1971	1972	1973	1974	1975	1976	1977	1978	1979	1980	1981	1982	1983	1984	1985	1986	1987	1988	1989	1990	1991	1992	1993	1994	1995	1996	1997	1998	1999	2000	2001	2002	2003	2004	2005	2006	2007	2008	2009	2010	2011	2012	2013	2014	2015	2016	2017	2018	2019	2020	2021	2022	2023	2024	2025	2026	2027	2028	2029	2030	2031	2032	2033	2034	2035	2036	2037	2038	2039	2040	2041	2042	2043	2044	2045	2046	2047	2048	2049	2050	2051	2052	2053	2054	2055	2056	2057	2058	2059	2060	2061	2062	2063	2064	2065	2066	2067	2068	2069	2070	2071	2072	2073	2074	2075	2076	2077	2078	2079	2080	2081	2082	2083	2084	2085	2086	2087	2088	2089	2090	2091	2092	2093	2094	2095	2096	2097	2098	2099	2100
1970	1971	1972	1973	1974	1975	1976	1977	1978	1979	1980	1981	1982	1983	1984	1985	1986	1987	1988	1989	1990	1991	1992	1993	1994	1995	1996	1997	1998	1999	2000	2001	2002	2003	2004	2005	2006	2007	2008	2009	2010	2011	2012	2013	2014	2015	2016	2017	2018	2019	2020	2021	2022	2023	2024	2025	2026	2027	2028	2029	2030	2031	2032	2033	2034	2035	2036	2037	2038	2039	2040	2041	2042	2043	2044	2045	2046	2047	2048	2049	2050	2051	2052	2053	2054	2055	2056	2057	2058	2059	2060	2061	2062	2063	2064	2065	2066	2067	2068	2069	2070	2071	2072	2073	2074	2075	2076	2077	2078	2079	2080	2081	2082	2083	2084	2085	2086	2087	2088	2089	2090	2091	2092	2093	2094	2095	2096	2097	2098	2099	2100	

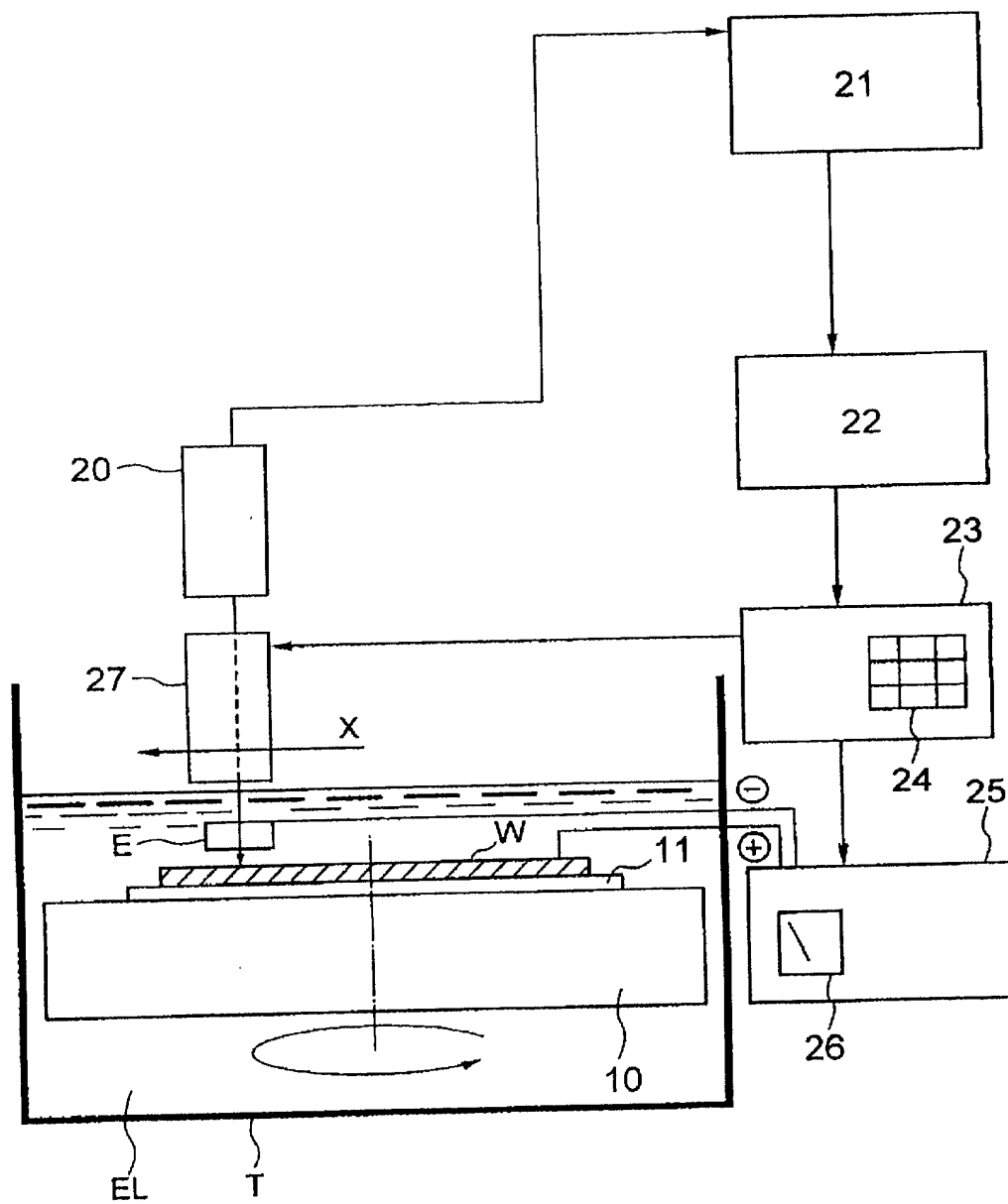


FIG.15

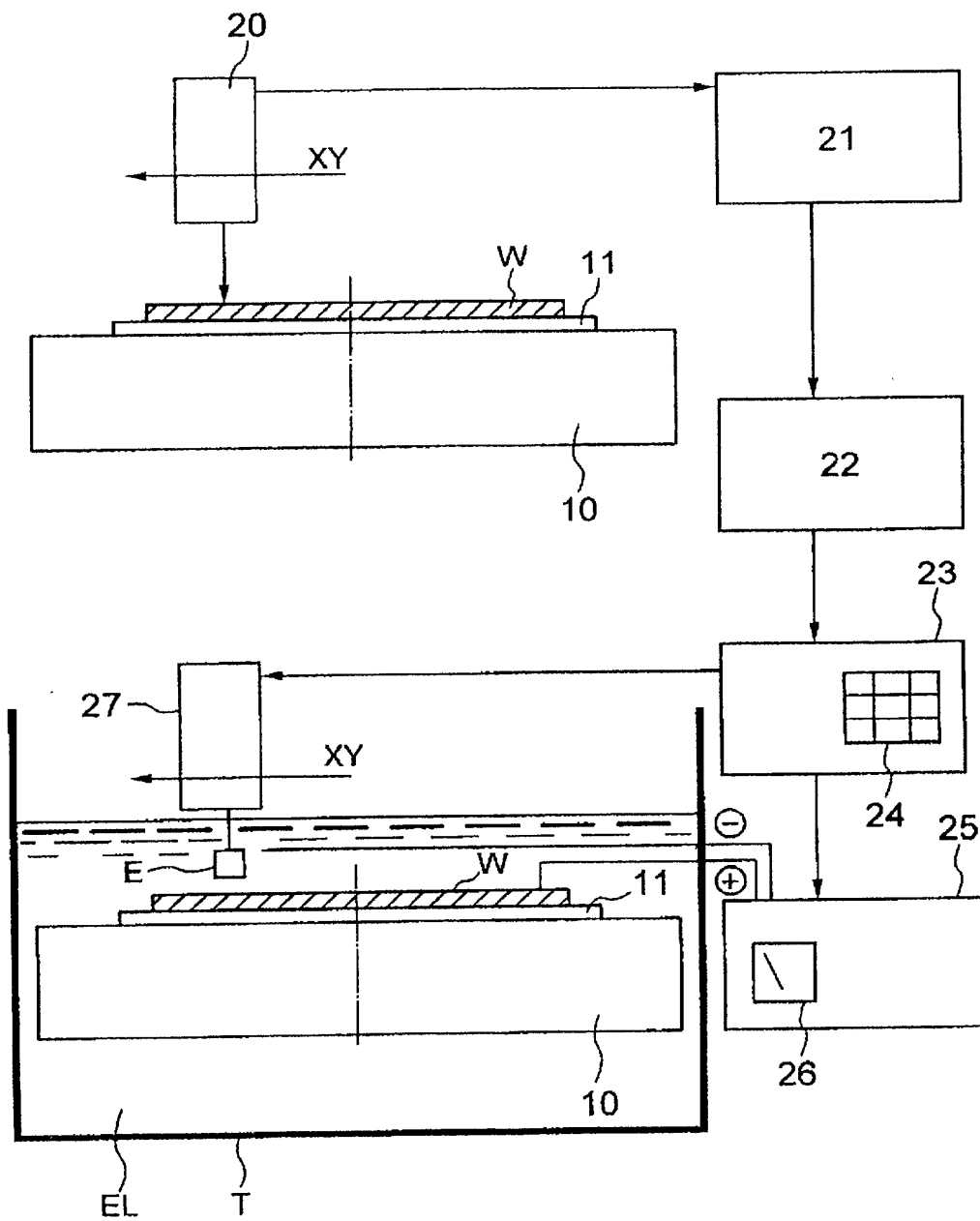


FIG.16A

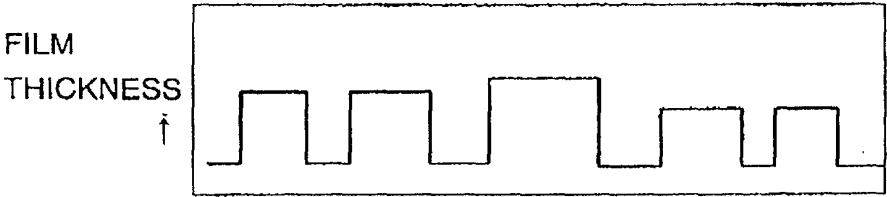


FIG.16B

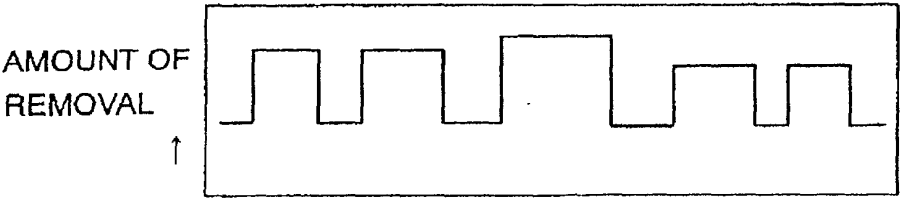


FIG.16C

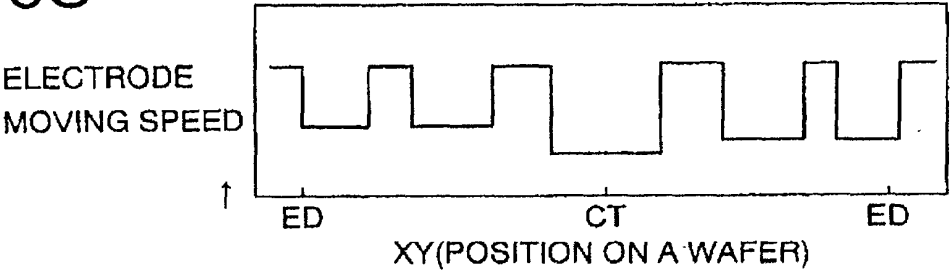
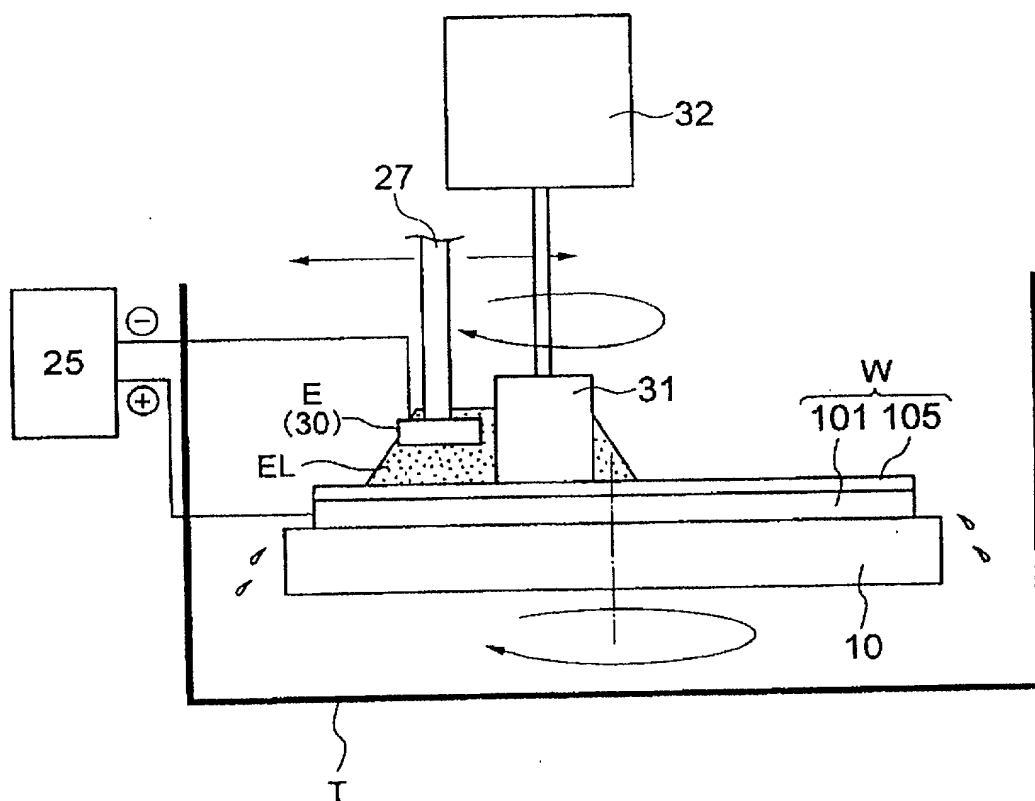


FIG. 17



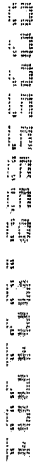
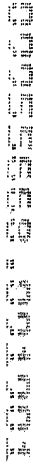
[illegible][illegible]

FIG.19A

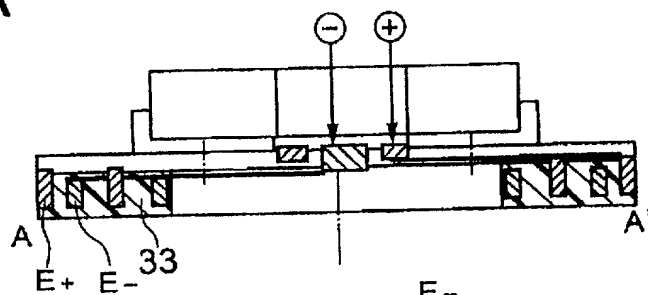


FIG.19B

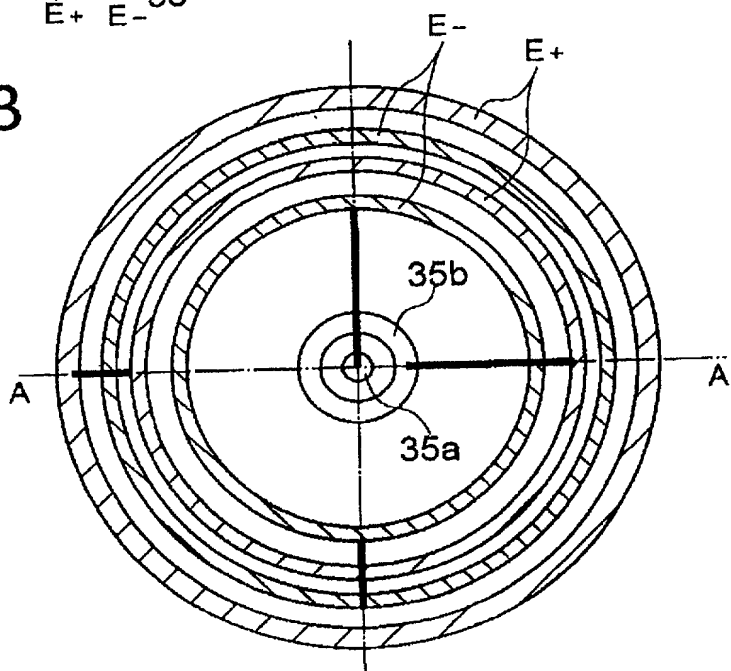


FIG.19C

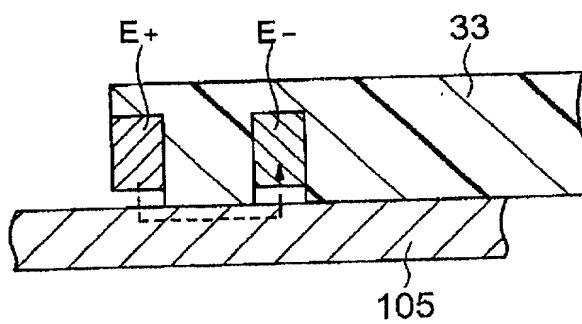


FIG.20A

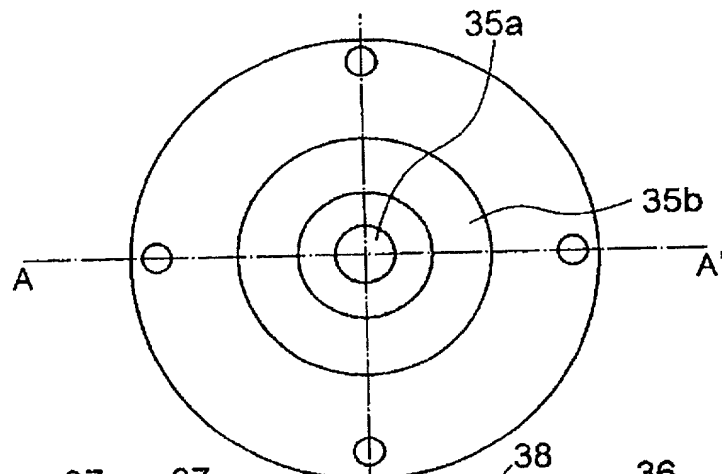


FIG.20B

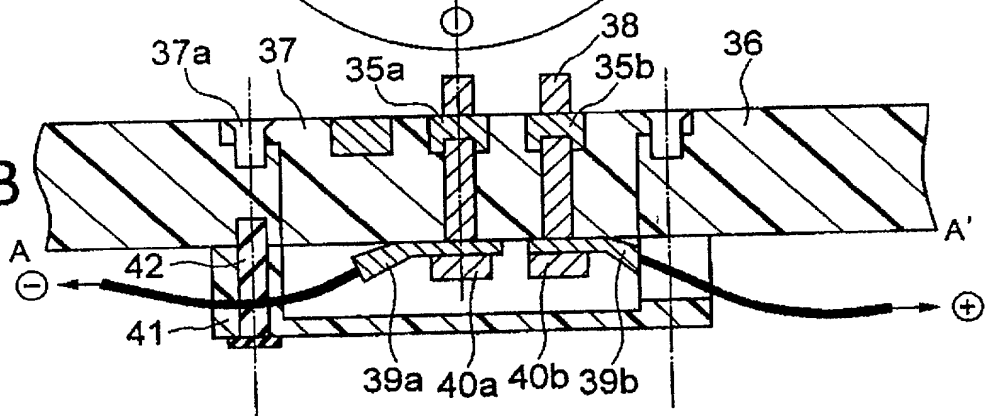


FIG.21A

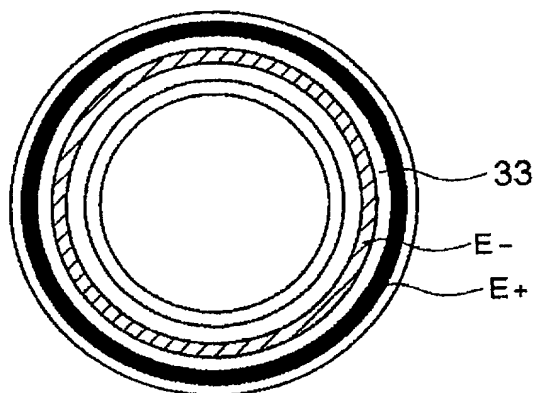


FIG.21B

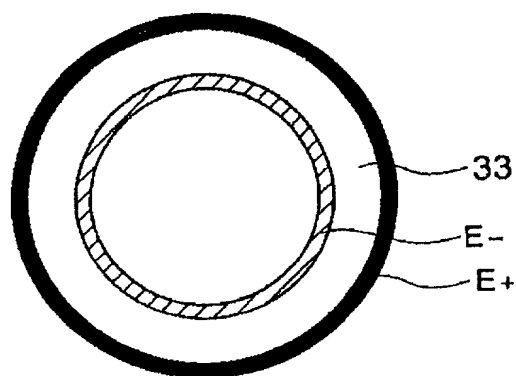


FIG.21C

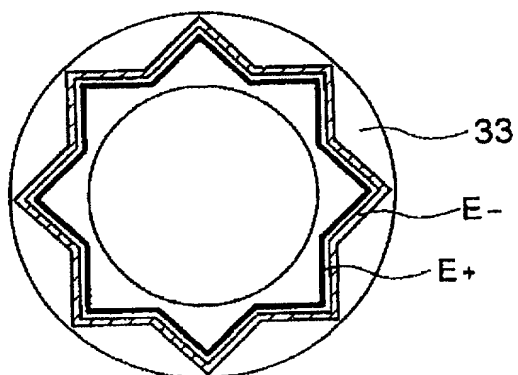


FIG.22A

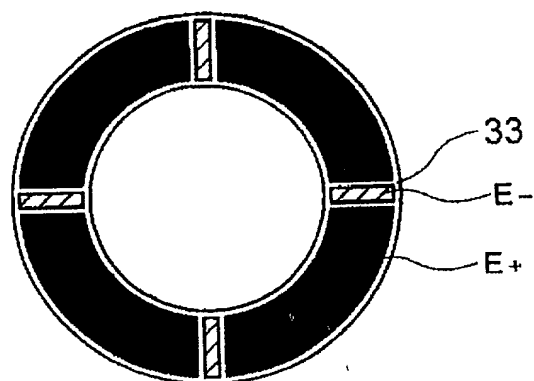


FIG.22B

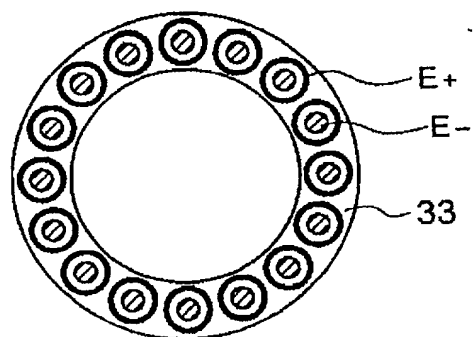


FIG.22C

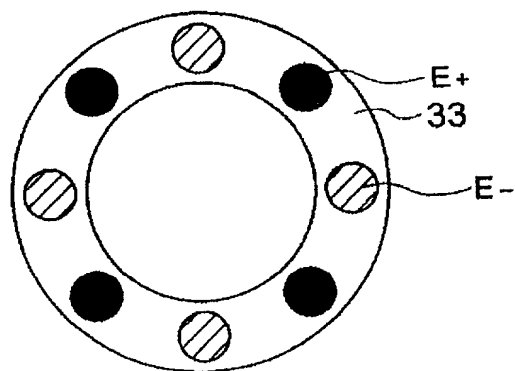


FIG.23A

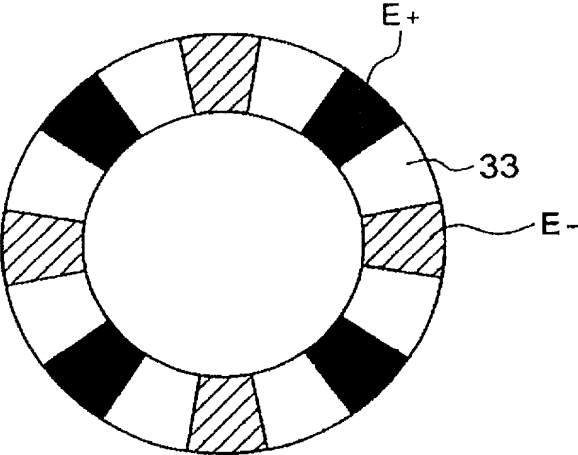


FIG.23B

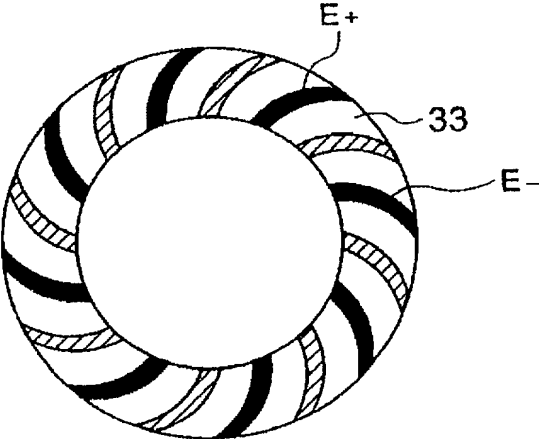


FIG.24A

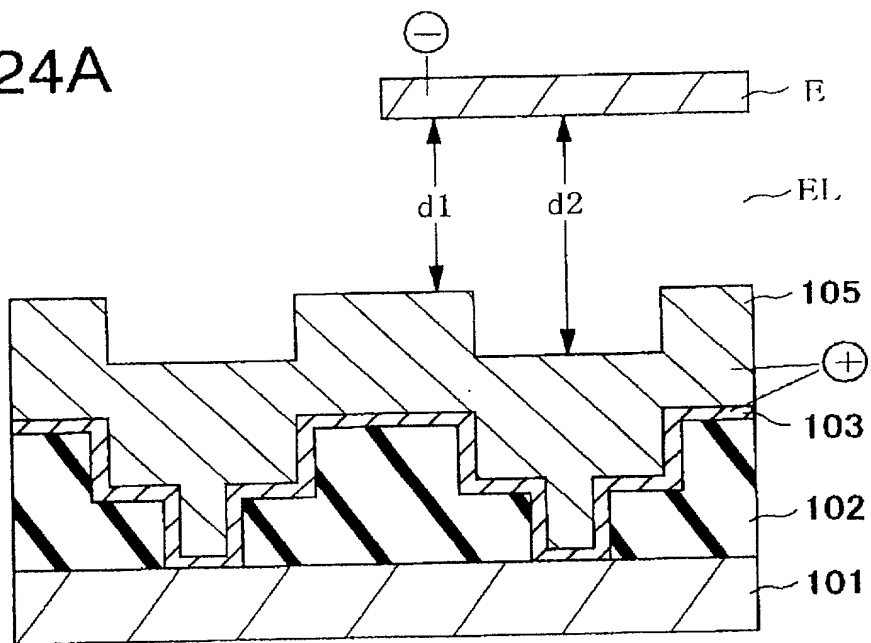


FIG.24B

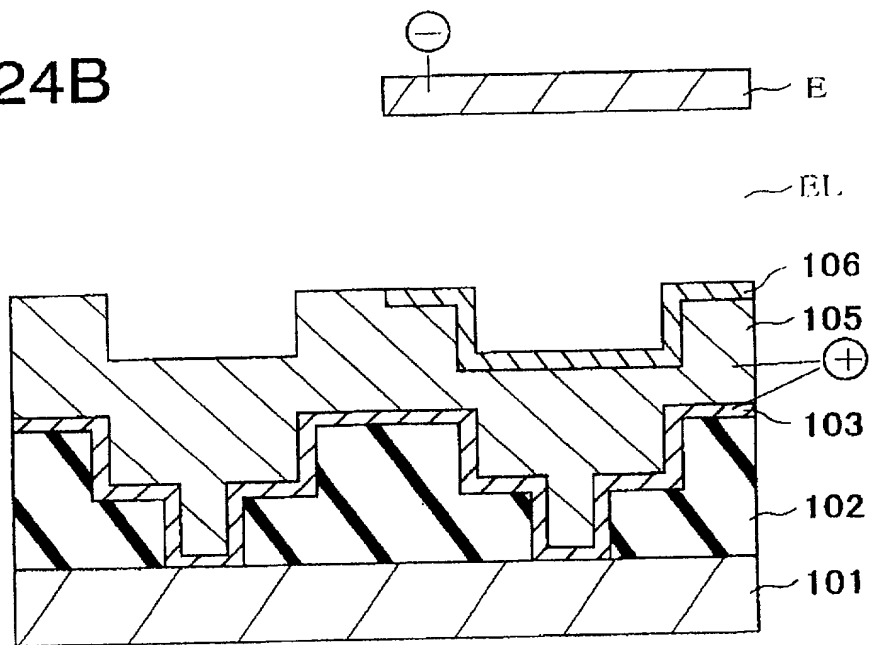


FIG.25A

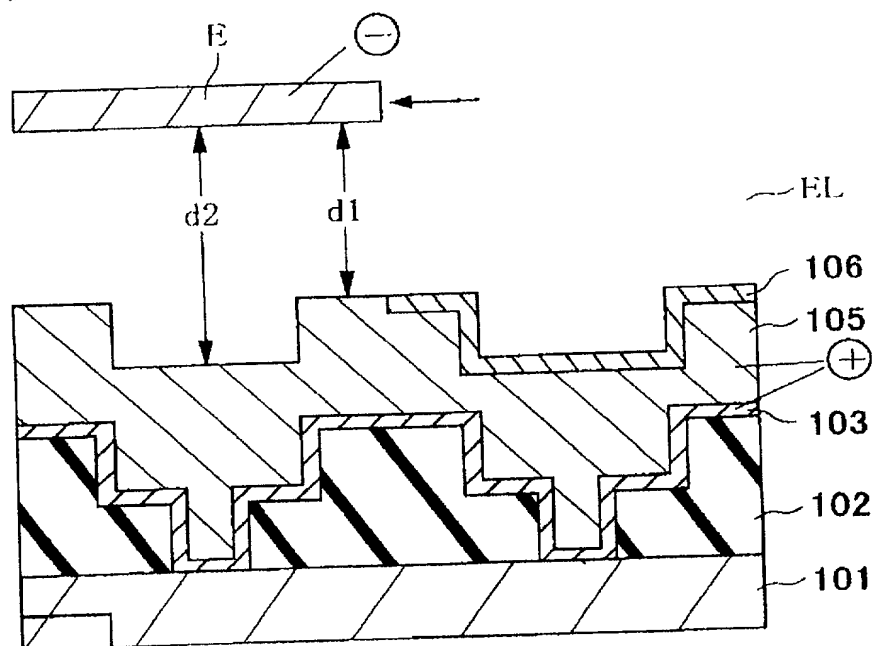


FIG.25B

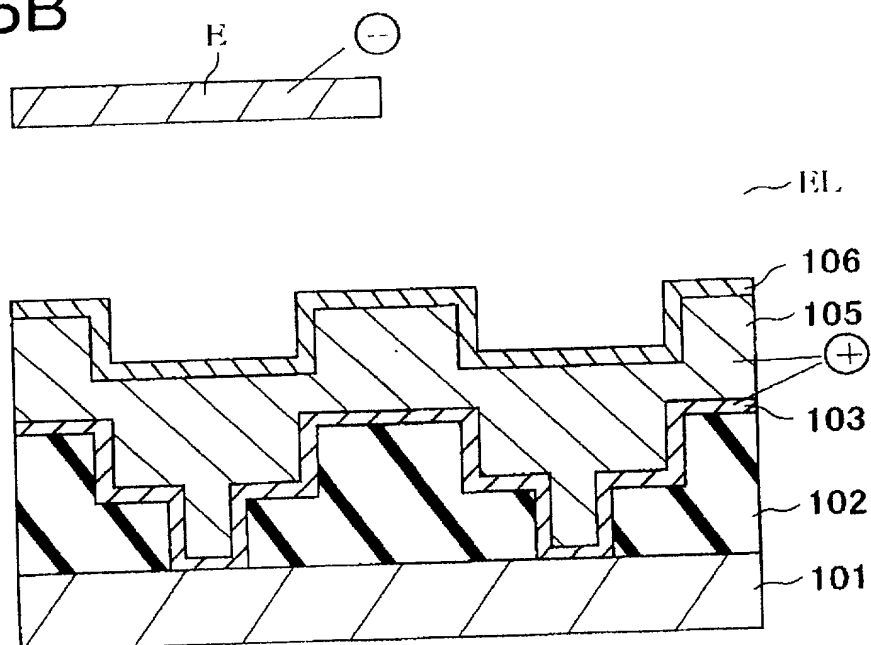


FIG.26A

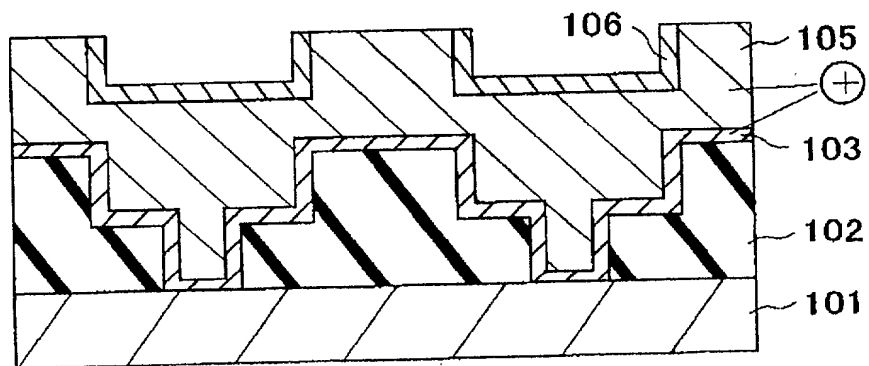


FIG.26B

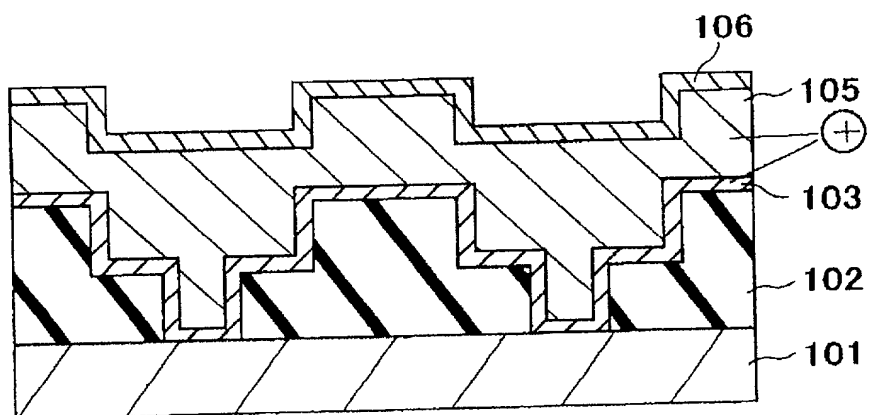
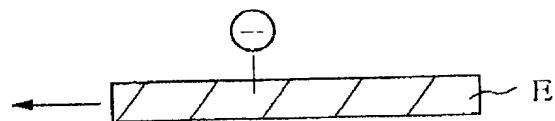


FIG.27A

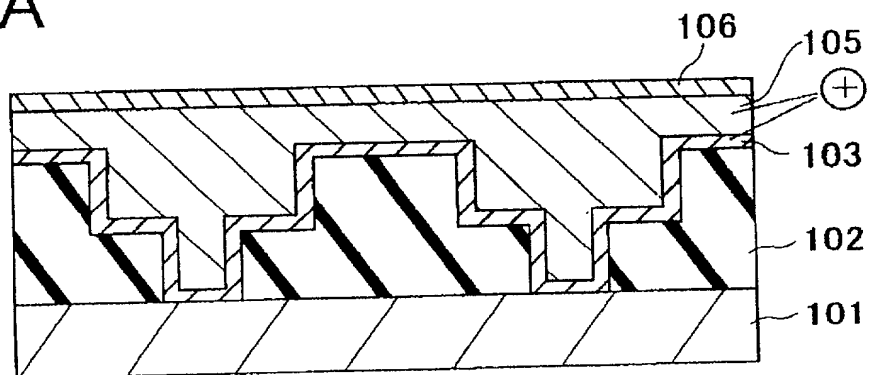


FIG.27B

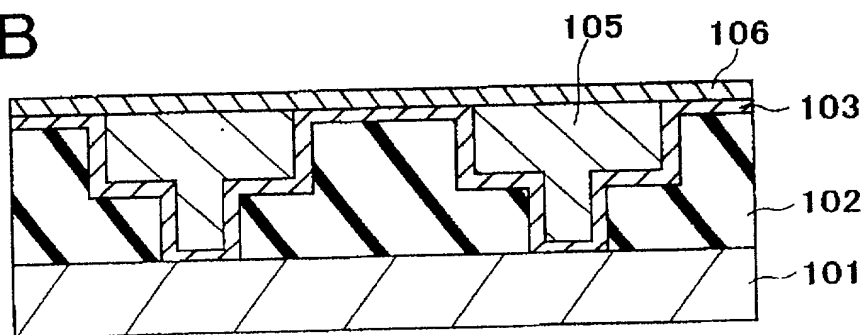


FIG.27C

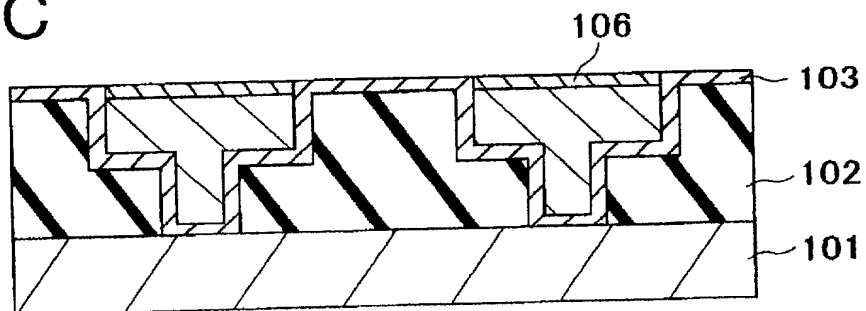


FIG. 28

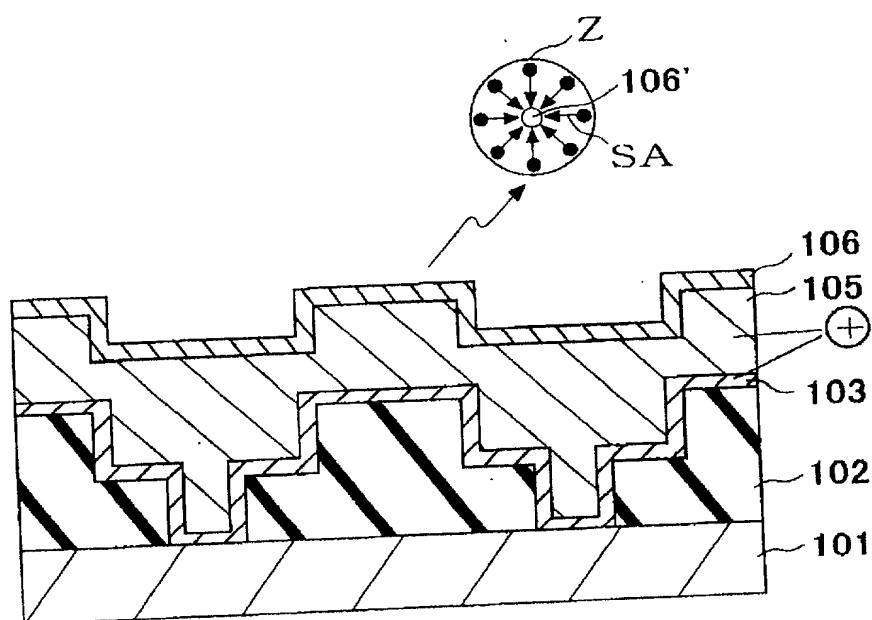


FIG. 29

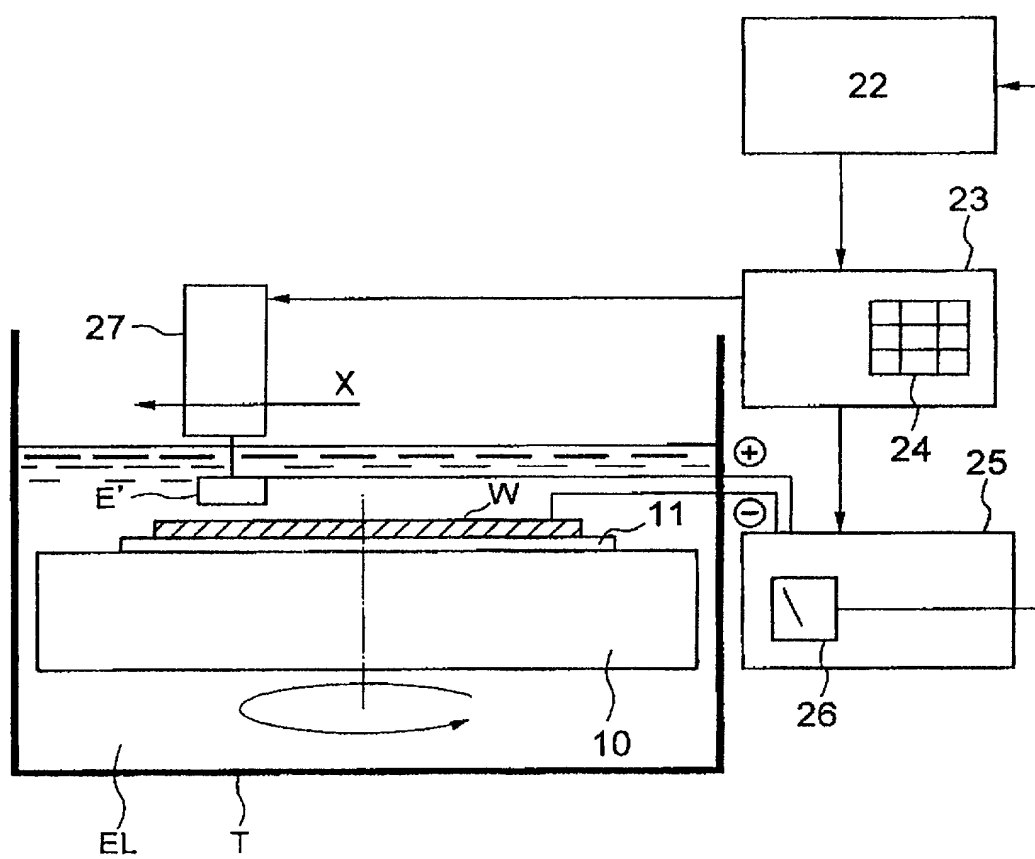


FIG.30A

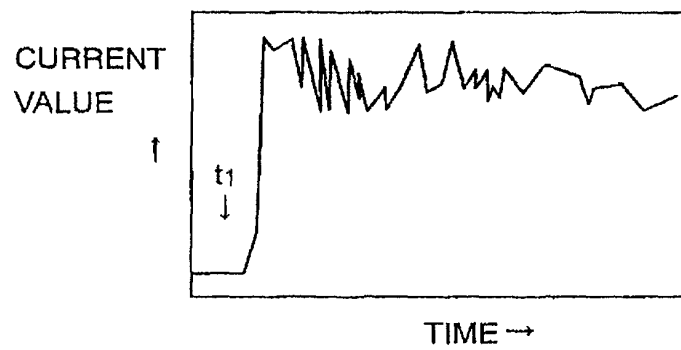


FIG.30B

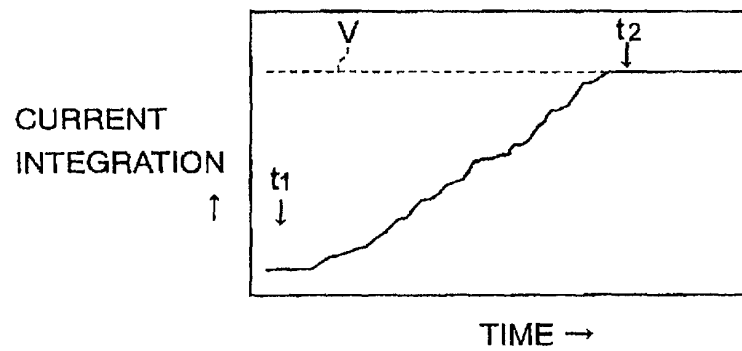


FIG. 31

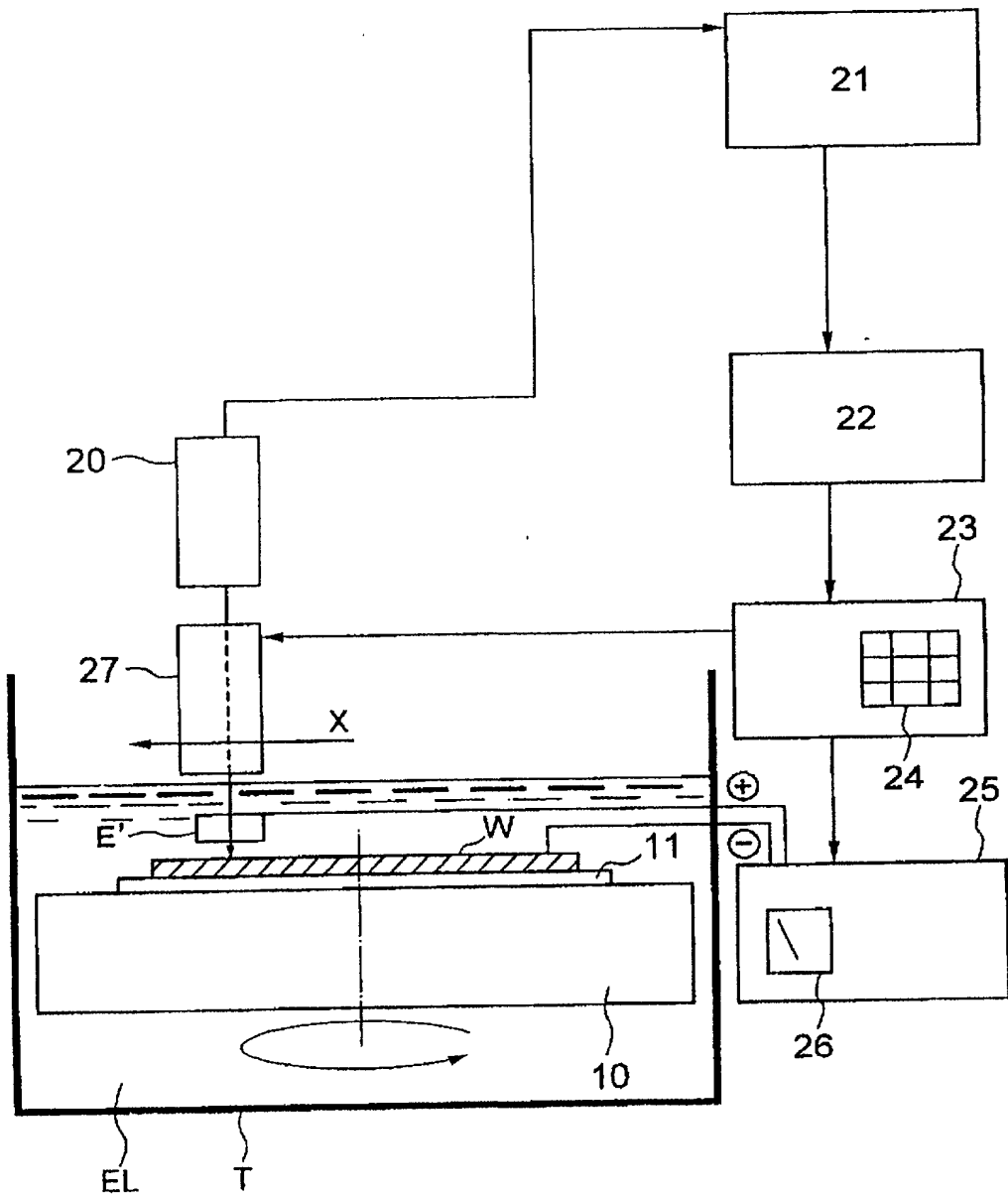


FIG. 32

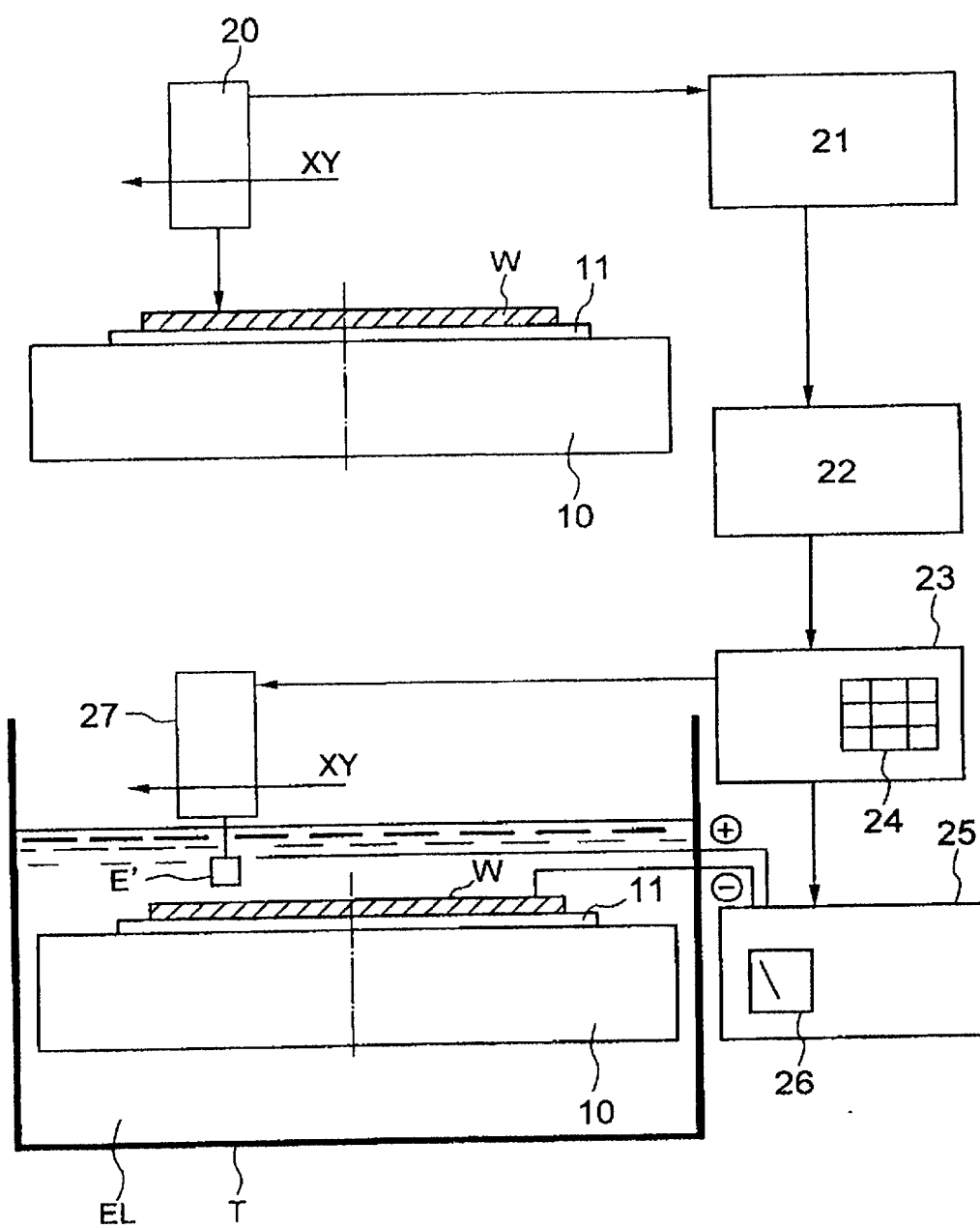


FIG.33A

SURFACE
THICKNESS

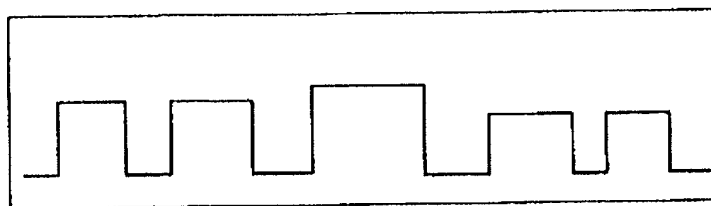


FIG.33B

AMOUNT OF
DEPOSITION

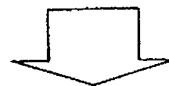
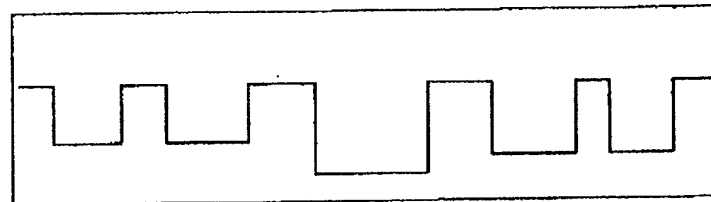
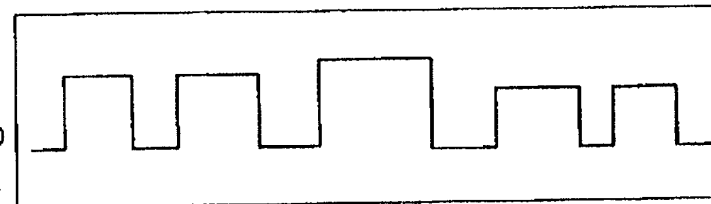


FIG.33C

ELECTRODE
MOVING SPEED



X(POSITION ON A WAFER)

FIG.34A

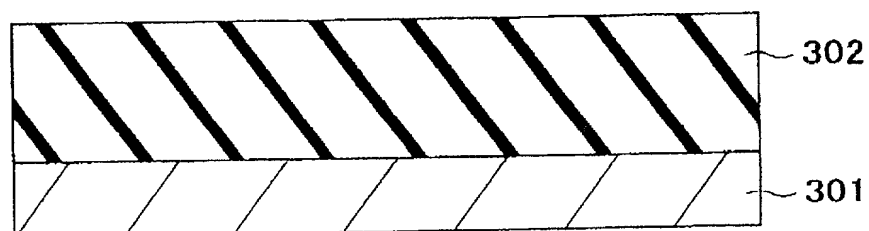


FIG.34B

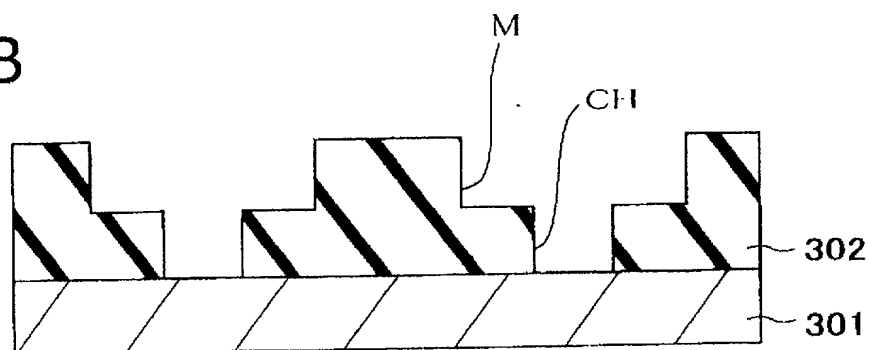


FIG.34C

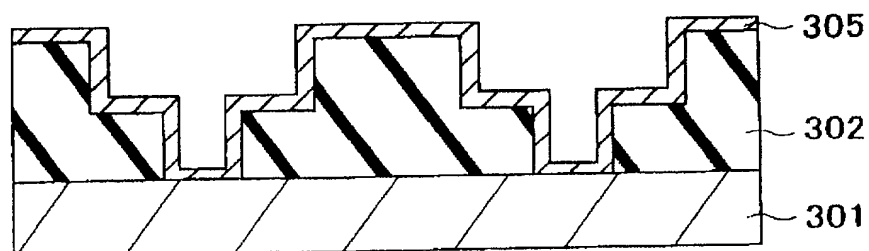


FIG.35A

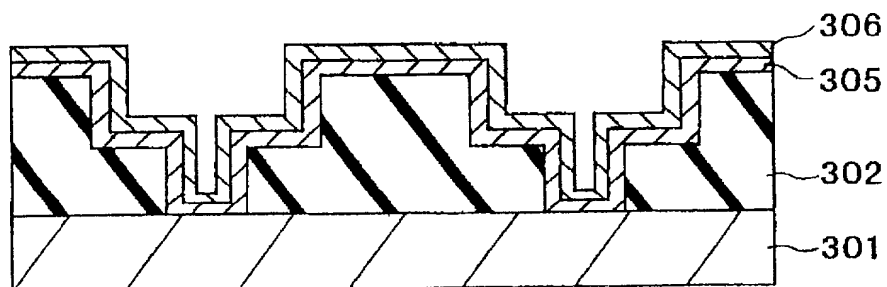


FIG.35B

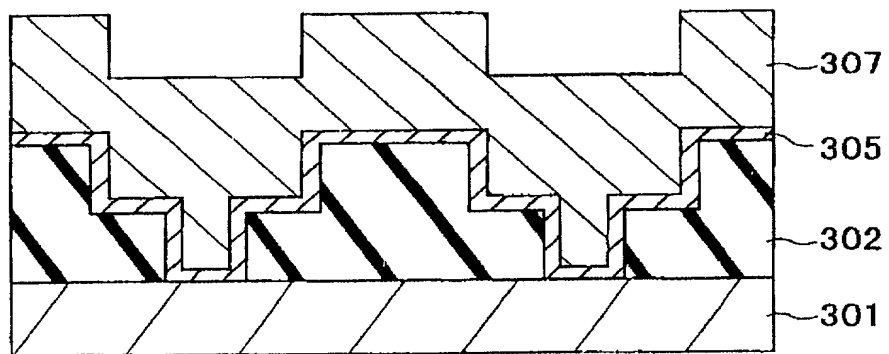


FIG.35C

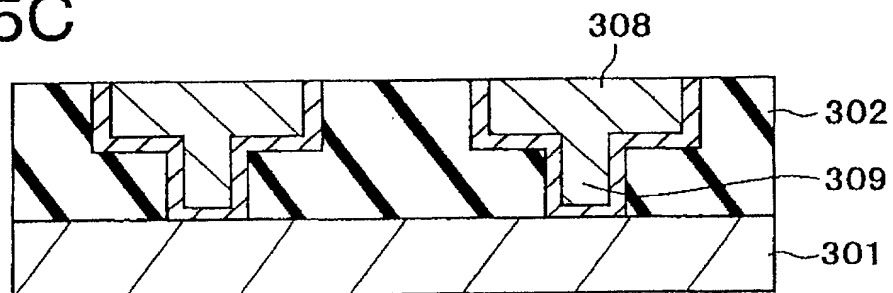


FIG. 36

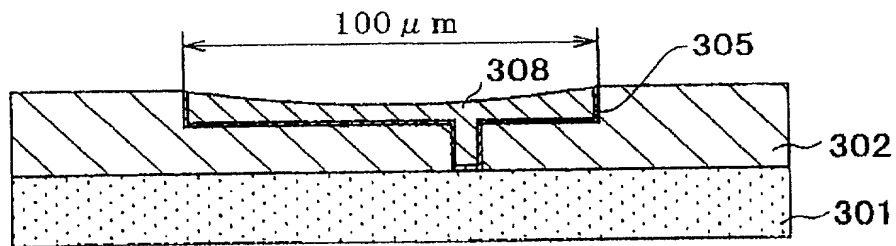


FIG. 37

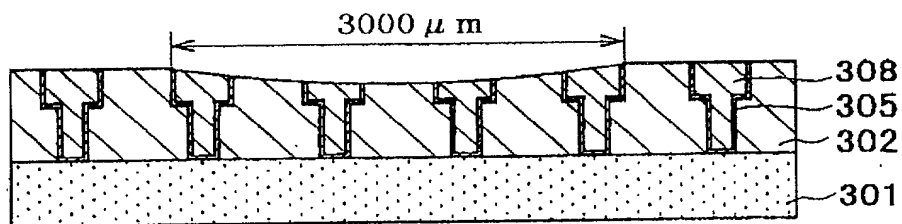


FIG. 38

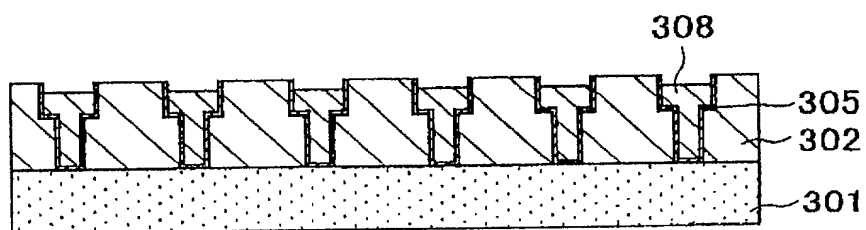


FIG. 39

